L	Hits	Search Text	DB	Time stamp
Number				
1	1243	(dry adj3 etching) adj10 (insulator or	USPAT;	2002/11/25
	1	inslating or insulate or oxide) same	US-PGPUB;	13:54
	l	substrate	EPO; JPO;]
			DERWENT;	
	}		IBM TDB	<u> </u>
2	481	(expose or exposed or exposing) adj10	USPAT;	2002/11/25
	((insulat or insulating or insulator) same	US-PGPUB;	13:55
		atmosphere	EPO; JPO;	1
		•	DERWENT;	l l
			IBM TDB	
3	9	((dry adj3 etching) adj10 (insulator or	USPAT;	2002/11/25
]	inslating or insulate or oxide) same	US-PGPUB;	13:55
		substrate) and ((expose or exposed or	EPO; JPO;	
	1	exposing) adj10 (insulat or insulating or	DERWENT;	,
		insulator) same atmosphere)	IBM TDB	

	Type	L#	Hits	Search Text	DBs	Time Stamp
1	IS&R	L1	468	(438/151).CCLS.	USPAT	2002/11/25 15:27
2	IS&R	L3	262	(438/695).CCLS.	USPAT	2002/11/25 15:41
3	IS&R	L4	390	(438/149).CCLS.	USPAT	2002/11/25 15:48
4	IS&R	ь7	323	(438/197).CCLS.	USPAT	2002/11/25 15:51
5	IS&R	L8	87	(438/142).CCLS.	USPAT	2002/11/25 16:05
6	IS&R	L9	321	(438/287).CCLS.	USPAT	2002/11/25 16:09